

#8 reconsideration  
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0941.65074

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re U.S. Patent Application )

Applicant: Chikayoshi Kamata )

Serial No. 09/748,919 )

Filed: December 27, 2000 )

For: GIANT MAGNETO-  
RESISTIVE DEVICE AND  
A FABRICATION PROCESS  
THEREOF )

Art Unit: 2652 )

Examiner: Nguyen, D. )

*I hereby certify that this paper is being deposited with the United States Postal Service as FIRST-CLASS mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231, on this date.*

1 Oct 02 *[Signature]*  
Date F-CLASS.WCM Registration No. 29367  
Appr. February 20, 1998 Attorney for Applicant

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Technology Center 2600

AMENDMENT A

Assistant Commissioner for Patents  
Washington, D.C. 20231

Dear Sir:

In response to the office action mailed June 19, 2002, please consider the following remarks.

REMARKS

Claim 1 stands rejected under § 102 on the basis of Chen et al. Applicant respectfully traverses this rejection for the following reasons.

It is the object of the present invention to provide an overlay type MR sensor with minimized oxidation of the cap layer covering the MR structure, by providing an